

HT-02-016

January 22, 2004

To: Commissioner for Patents  
P.O.Box 1450  
Alexandria, VA 22313-1450

Fr: George O. Saile, Reg. No. 19,572  
28 Davis Avenue  
Poughkeepsie, N.Y. 12603

Subject: | Serial No. 10/706,381 11/12/03 |  
Moris Dovek et al.  
WRITE-HEAD HAVING RECESSED MAGNETIC  
MATERIAL IN GAP REGION  
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INFORMATION DISCLOSURE STATEMENT

Enclosed is Form PTO-1449, Information Disclosure Citation  
In An Application.

The following Patents and/or Publications are submitted to  
comply with the duty of disclosure under CFR 1.97-1.99 and  
37 CFR 1.56.

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being  
deposited with the United States Postal Service as first class  
mail in an envelope addressed to: Commissioner for Patents,  
P.O. Box 1450, Alexandria, VA 22313-1450, on January 27, 2004.

Stephen B. Ackerman, Reg.# 37761

Signature/Date

SB Ackerman 1/27/04

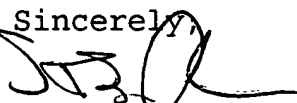
U.S. Patent 6,353,511 to Shi et al., "Thin Film Write Head for Improved High Speed and High Density Recording," discloses a process for a improved write head.

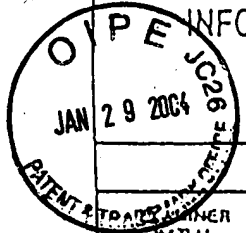
U.S. Patent 5,878,481 to Feng et al., "Pole Trimming Method for Fabricating a Magnetic Transducer Structure," discloses a pole trimming process for a write head.

U.S. Patent 5,843,521 to Ju et al., "Photoresist Frame Plated Magnetic Transducer Pole Layer Employing High Magnetic Permeability Seed Layer," discloses a method for forming a magnetic transducer, and a magnetic transducer formed through the method.

U.S. Patent 5,802,700 to Chen et al., "Method of Making a Planarized Thin Film Magnetic Write Head with Submicron Trackwidth," discloses a method for making a thin film magnetic write head with a notch stucture located on top of one of two pole layers.

U.S. Patent 5,652,687 to Chen et al., "Planarized Thin Film Magnetic Write Head with Submicron Trackwidth," discloses a planarized write head process.

Sincerely,  
  
Stephen B. Ackerman,  
Reg. No. 37761



Form PTO-1449	Document Number (Optional) <b>HT-02-016</b>	Application Number <b>10/706,381</b>
INFORMATION DISCLOSURE CITATION IN AN APPLICATION		
Applicant <b>Moris Dorek et al.</b>		
Filing Date <b>11/12/03</b>		Group Art Unit
(Use several sheets if necessary)		

U. S. PATENT DOCUMENTS

DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILED DATE IF APPROPRIATE
6353511	3/5/02	Shi et al.	360	126	6/15/99
5878481	3/9/99	Feng et al.	29	603.15	4/28/97
5843521	12/1/98	Ju et al.	427	129	7/21/97
5802700	9/8/98	Chen et al.	29	603.14	6/6/95
5652687	7/29/97	Chen et al.	360	126	9/21/95

FOREIGN PATENT DOCUMENTS

DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
					YES	NO

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)


EXAMINER	DATE CONSIDERED
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.